# PLASMA ARRAY (LARGE AREA) - MA6000Y-023BC

**Category:** Plasma components



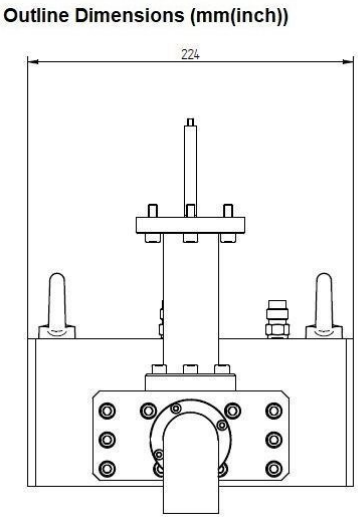

## BESCHREIBUNG

A combination of duo-plasmalines can be used to obtain a two dimensional plasma array. Single sources as well as 2, 4 and 8 parallel arranged plasmalines are available for plasma assisted surface treatment like surface activating, etching and deposition.

- Low pressure mirowave plasma source
- Suitable for cleaning, etching, ashing, deposition, sterilization, pretreatment
- Compact design
- Easy adaption to customer systems
- Integrated gas shower
- High plasma density
- High efficiency

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## ADDITIONAL INFORMATION

| | |
|---|---|
| **Typ** | Plasma array (large area) |
| **Process** | Etching & Deposition |
| **Output Connection Type** | Plasma area 797,5 mm x 150 mm |
| **Dielectric material** | Ceramics |
| **Output Power CW [W]** | 2x 3000 |
| **Frequency [MHz]** | 2450 |
| **Gas manifold** | Double |

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